

IN THE CLAIMS

Please amend the claims as follows:

Claim 1 (Currently Amended): A transparent substrate (6), comprising on at least one of its faces an antireflection coating, particularly at normal incidence made of a multilayer (A) of thin layers made of dielectrical material with alternatively high and low refractive indexes, characterized in that the multilayer comprises, in succession:

a high-index first layer (1) comprising a mixed oxide of Sn and Zn doped or not doped, with a refractive index n_1 of between 1.8 and 2.2 and geometrical thickness e_1 of between 5 and 50 nm,

a low-index second layer (2) comprising SiO_2 , with a refractive index n_2 of between 1.35 and 1.65 and a geometrical thickness e_2 of between 5 and 50 nm,

a high-index third layer (3) comprising a mixed oxide of Sn and Zn doped or not doped, with a refractive index n_3 of between 1.8 and 2.2 and a geometrical thickness e_3 of between 40 and 150 nm,

a low-index depth fourth layer (4) comprising SiO_2 , with a refractive index n_4 of between 1.35 and 1.65 and a geometrical thickness e_4 of between 40 and 120 nm.

Claim 2 (Currently Amended): The substrate (6) as claimed in claim 1, wherein n_1 and/or n_3 are between 1.85 and 2.15, ~~particularly between 1.90 and 2.10.~~

Claim 3 (Cancelled).

Claim 4 (Currently Amended): The substrate (6) as claimed in claim 1, wherein e_1 is between 5 and 50 nm, ~~particularly between 10 and 30 nm or between 15 and 25 nm.~~

Claim 5 (Currently Amended): The substrate (6) as claimed in claim 1, wherein e_2 is between 5 and 50 nm, ~~particularly less than or equal to 35 nm or to 30 nm, particularly being between 10 and 35 nm.~~

Claim 6 (Currently Amended): The substrate (6) as claimed in claim 1, wherein e_3 is between 45 and 80 nm.

Claim 7 (Currently Amended): The substrate (6) as claimed in claim 1, wherein e_4 is between 45 and 110 nm ~~and preferably between 70 and 100 nm.~~

Claim 8 (Currently Amended): A substrate (6) as claimed in Claim 1 wherein the high-index first layer (1) and the low-index second layer (2) are replaced by an intermediate-index single layer (5) e_s of between 1.65 and 1.80 and preferably having an optical thickness e_{opt5} of between 50 and 140 nm, preferably between 85 and 120 nm.

Claim 9 (Currently Amended): The substrate (6) as claimed in claim 8, wherein the intermediate-index layer (5) is based on a mixture of, ~~on the one hand,~~ silicon oxide and, ~~on the other hand,~~ at least one metal oxide chosen from tin oxide, zinc oxide, titanium oxide or is based on a silicon oxynitride or oxycarbide and/or aluminum oxynitride.

Claims 10-12 (Cancelled)

Claim 13 (Currently Amended): The substrate ~~[(6)]~~ as claimed in claim 1, wherein said substrate is made of clear or bulk-tinted glass.

Claim 14 (Previously Presented): The substrate as claimed in claim 1, wherein its light reflection on the side on which it is equipped with the multilayer made up of thin layers is lowered by a minimum amount of 3 or 4% at a normal angle of incidence.

Claim 15 (Previously Presented): The substrate as claimed in claim 1, wherein the colorimetry of its light reflection on the side on which it is equipped with the multilayer made up of thin layers is such that the corresponding b^* value in the (L^* , a^* , b^*) colorimetry system is negative, at a normal angle of incidence.

Claims 16 -18 (Cancelled).

Claim 19 (Currently Amended): The substrate (6) as claimed in claim 1, wherein it is equipped on one of its faces with the anti-reflection multilayer and, on its other face, either with no antireflection multilayer or also with an antireflection multilayer, or with another type of antireflection coating, or with a coating having ~~some~~ another functionality of ~~[[the]]~~ solar protection, low emissivity, antifouling, antifogging, antirain or heating ~~type~~.

Claim 20 (Currently Amended): The substrate as claimed in claim 19, wherein the other type of antireflection coating is chosen from the following coatings:

a single layer with a low index, lower than 1.60 or 1.50, ~~particularly of about 1.35–1.48, particularly based on silicon oxide,~~

a single layer the refractive index of which varies through its thickness, ~~particularly of the silicon oxynitride SiO_xN_y type, with x and y varying through its thickness,~~

a two-layer multilayer comprising, in succession, a layer with a high index of at least 1.8, particularly tin oxide, zinc oxide, zirconium oxide, titanium oxide, silicon or aluminum nitride, followed by a layer with a low index, below 1.65, ~~particularly made of silicon oxide, oxynitride or oxycarbide,~~

three-layer multilayer comprising, in succession, a layer of medium index of between 1.65 and 1.8 of the silicon and/or aluminum oxycarbide or oxynitride type, a layer with a high index above 1.9 of the SnO_2 , TiO_2 type, a layer with a low index less than 1.65 of the mixed Si-Al oxide or silicon oxide type antifouling coating.

Claim 21 (Currently Amended): A multiple glazed unit, ~~particularly a double glazed unit, or unit with a laminated structure,~~ comprising at least two substrates as claimed in claim 1, wherein the two glass substrates ~~(6, 6')~~ are combined using a sheet ~~(7)~~ of thermoplastic, the substrate ~~(6)~~ being equipped, on the opposite side to the assembly, with the antireflection multilayer and the substrate ~~(6')~~ being equipped, on the opposite side to the assembly, with either no antireflection coating or also an antireflection coating, or with another type of antireflection coating, or with a coating having another functionality of the solar protection, low emissivity, antifouling, antifogging, antirain or heating type, it also being possible for said coating with another functionality to be located on one of the faces of the substrates that face toward the thermoplastic sheet used for assembly.

Claim 22 (Withdrawn): A method for producing the glazing as claimed in claim 21, comprising depositing the antireflection multilayer or multilayers by cathode sputtering and

optionally depositing an antireflection coating by a sol-gel technique, a pyrolysis technique of the CVD, or plasma CVD type, by cathode sputtering or by corona discharge.

Claim 23 (Previously Presented): A glazed product produced by the glazing method as claimed in claim 21 wherein said glazed product is an interior or exterior glazing for buildings, a display cabinet, a counter in stores, that may be curved, an anti-dazzle computer screen, or a glass furniture.